



## Recent Advances in Wastewater Treatment and Transport

Guest Editors:

**Dr. Harsha Ratnaweera**

Faculty of Science and  
Technology, Norwegian  
University of Life Sciences, 0870  
Oslo, Norway

**Dr. Xiaodong Wang**

School of Environmental and  
Municipal Engineering, Qingdao  
University of Technology,  
Qingdao, China

Deadline for manuscript  
submissions:

**closed (15 May 2024)**

### Message from the Guest Editors

We hope that the Special Issue will become a platform for sharing innovative ideas and practice experience of recent advances in wastewater treatment processes as well as sewer networks. Topics include, but are not limited to:

- Partial nitrification/denitrification and anammox processes
- Efficient particle separation processes
- Advanced Oxidation processes for organic matter removal in industrial wastewater
- New processes for resource recovery from wastewater
- Sewer network monitoring and control
- Wastewater treatment process monitoring and control
- Processes for emerging contaminants removal
- Electro-chemical and bioelectrochemistry processes for nonbiodegradable matters removal
- Bio-electrolysis processes





an Open Access Journal by MDPI

## Editor-in-Chief

### Prof. Dr. Giancarlo Cravotto

Department of Drug Science and  
Technology, University of Turin,  
Via P. Giuria 9, 10125 Turin, Italy

## Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

## Author Benefits

**Open Access:** free for readers, with article processing charges (APC) paid by authors or their institutions.

**High Visibility:** indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

**Journal Rank:** JCR - Q2 (*Engineering, Chemical*) / CiteScore - Q2 (*Chemical Engineering (miscellaneous)*)

## Contact Us

---

Processes Editorial Office  
MDPI, Grosspeteranlage 5  
4052 Basel, Switzerland

Tel: +41 61 683 77 34  
[www.mdpi.com](http://www.mdpi.com)

[mdpi.com/journal/processes](http://mdpi.com/journal/processes)  
[processes@mdpi.com](mailto:processes@mdpi.com)  
[X@Processes\\_MDPI](https://twitter.com/Processes_MDPI)